



**PATENT APPLICATION**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Masaru MITSUI

Application No.: 10/523,470

Docket No.: 122672

Filed: March 10, 2005

For: METHOD FOR MANUFACTURING MASK BLANK, METHOD FOR  
MANUFACTURING TRANSFER MASK, SPUTTERING TARGET FOR  
MANUFACTURING MASK BLANK

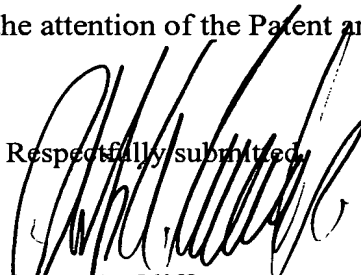
**REQUEST FOR CORRECTION OF PALM RECORDS**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

  
James A. Oliff  
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JAO:PAC/crh

Date: August 31, 2005

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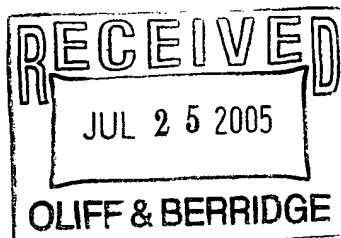


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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/523,470	03/10/2005	1756	1030	122672	3	11	3

25944  
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CONFIRMATION NO. 3658

## FILING RECEIPT



\*OC000000016544703\*

Date Mailed: 07/20/2005

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

## Applicant(s)

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## Assignment For Published Patent Application

Hoya Corporation, Tokyo, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 25944.

## Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/10438 08/19/2003

## Foreign Applications

JAPAN 2002-238564 08/19/2002

Projected Publication Date: 10/27/2005

Non-Publication Request: No

Early Publication Request: No

## Title

~~Mask blank manufacturing method, transfer mask manufacturing method, sputtering target for~~  
**METHOD FOR MANUFACTURING MASK BLANK, METHOD FOR MANUFACTURING**  
**TRANSFER MASK, SPUTTERING TARGET FOR MANUFACTURING MASK BLANK**

~~manufacturing mask blank~~**Preliminary Class**

430

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